

Abstract of the Disclosure

An antireflection film [has] is formed of an organic film [1], and a hard-coating layer [2], [an electrically conductive] a high refractive index layer [3] and a low refractive index layer 4[, in which the layers 2, 3 and 4 are] laminated [on the organic film 1,] in this order[. The high refractive index layer 3 includes particles composed of two or more types of metal oxide, in which at least one of two or more types of the metal oxide is electrically conductive metal oxide. The high refractive index layer 3 has an exceedingly high refractive index. The low refractive index layer 4 may have a relatively high refractive index] on the organic film. The high refractive index layer is formed of metal oxide particles of ITO with electrical conductivity and TiO₂ with high refractive index, and synthetic resin. A volume percentage of the TiO₂ particles to a total volume of the TiO₂ and ITO particles in the high refractive index layer is 1 to 60%, and a volume percentage of the metal oxide particles to a total volume of the metal oxide particles and the synthetic resin is 20% or more.